

EE 330

Lecture 36

High Frequency Operation of Amplifiers

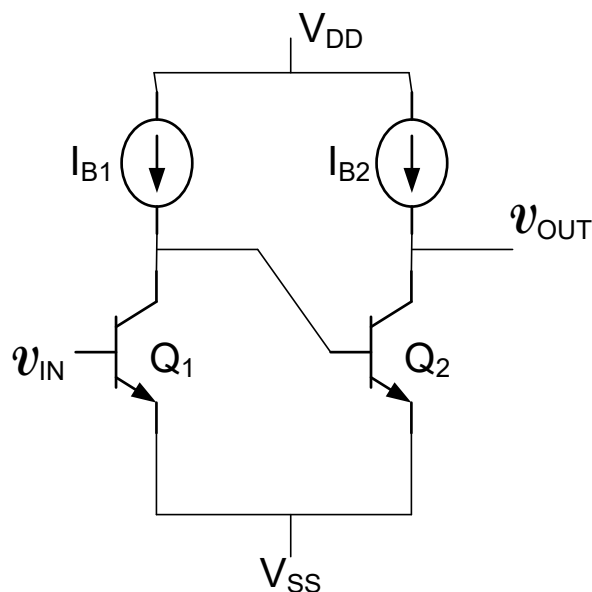
Digital Circuit Design

Hierarchical Design

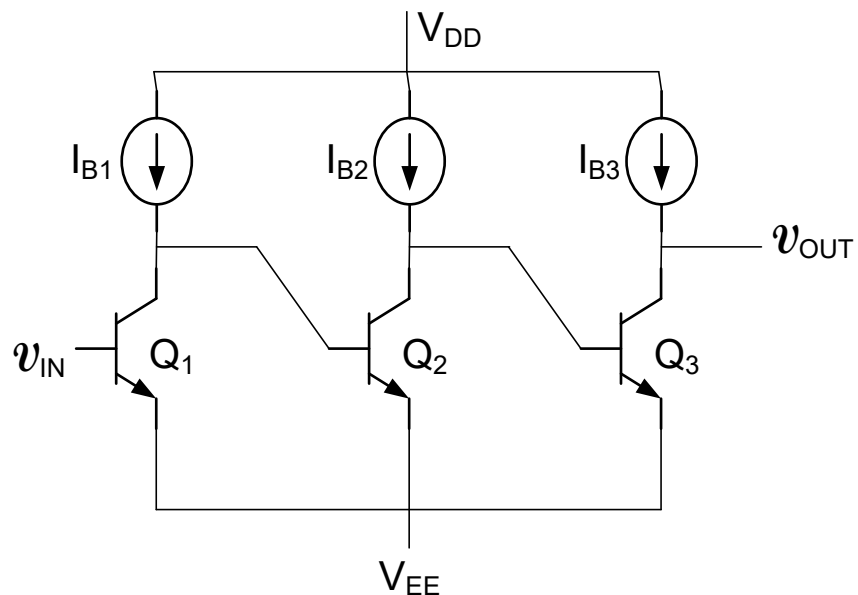
Fall 2025 Exam Schedule

Exam 1	Friday	Sept 26
Exam 2	Friday	October 24
Exam 3	Friday	Nov 21
Final Exam	Monday	Dec 15 12:00 - 2:00 PM

Cascade Configurations



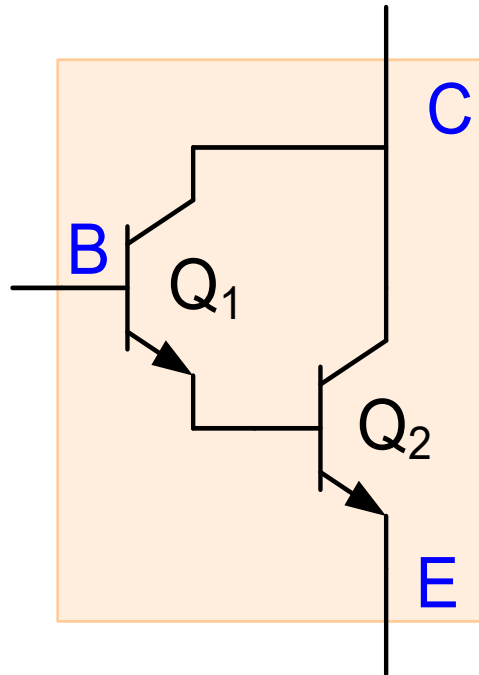
Two-stage CE Cascade



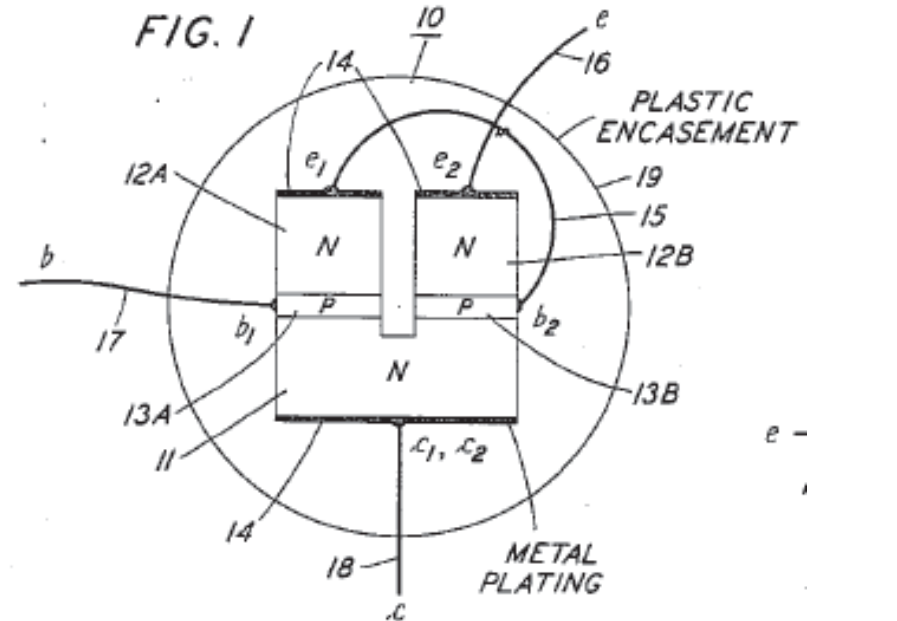
Three-stage CE Cascade

- Large gains can be obtained by cascading
- Gains are multiplicative (when loading is included)
- Large gains used to build “Op Amps” and feedback used to control gain value
- Some attention is needed for biasing but it is manageable
- Minor variant of the two-stage cascade often used to build Op Amps
- Compensation of two-stage cascade needed if feedback is applied to maintain stability
- For many years three or more stages were seldom cascaded because of challenges in compensation to maintain stability though recently some industrial adoptions

Other Basic Configurations



Darlington Configuration



S. DARLINGTON

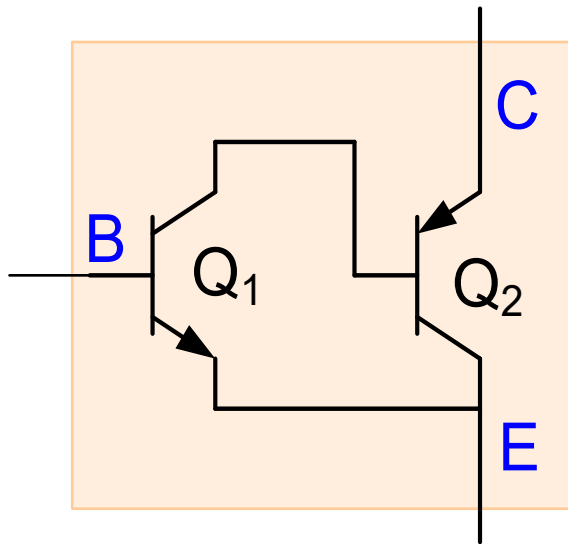
2,663,806

SEMICONDUCTOR SIGNAL TRANSLATING DEVICE

Filed May 9, 1952

- Current gain is approximately β^2
- Two diode drop between B_{eff} and E_{eff}

Other Basic Configurations



Sziklai Pair

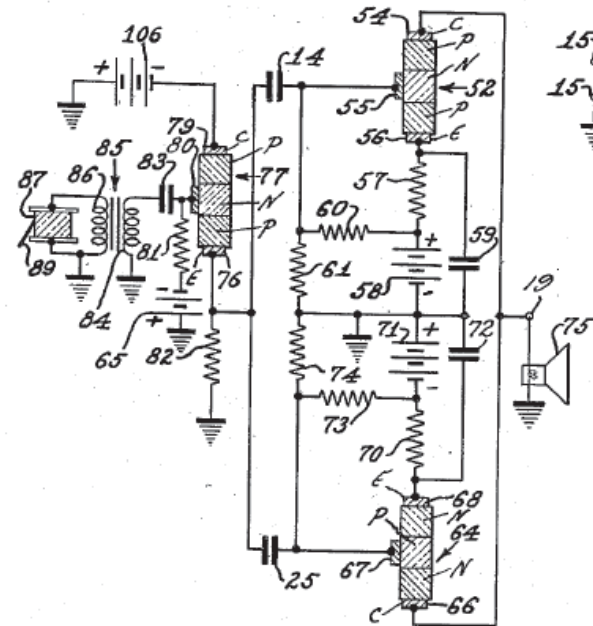


FIG. 3.

May 7, 1957

G. C. SZIKLAI

2,791,644

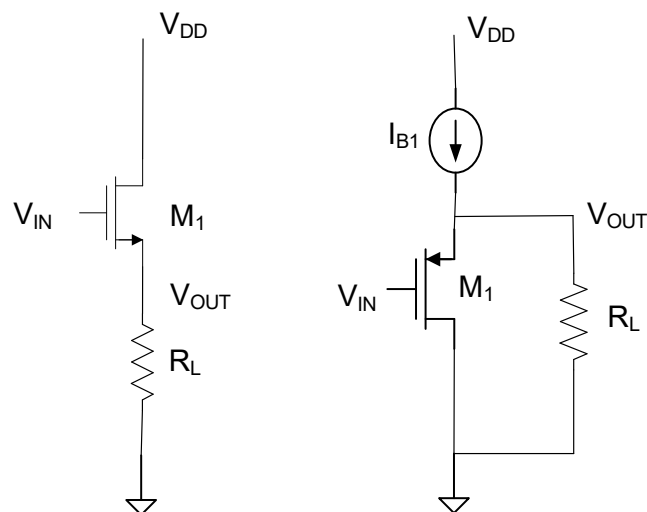
PUSH-PULL AMPLIFIER WITH COMPLEMENTARY TYPE TRANSISTORS

Filed Nov. 7, 1952

- Gain similar to that of Darlington Pair
- Current gain is approximately $\beta_n \beta_p$
- Current gain will not be as large when $\beta_p < \beta_n$
- Only one diode drop between B_{eff} and E_{eff}

Other Basic Configurations

Buffer



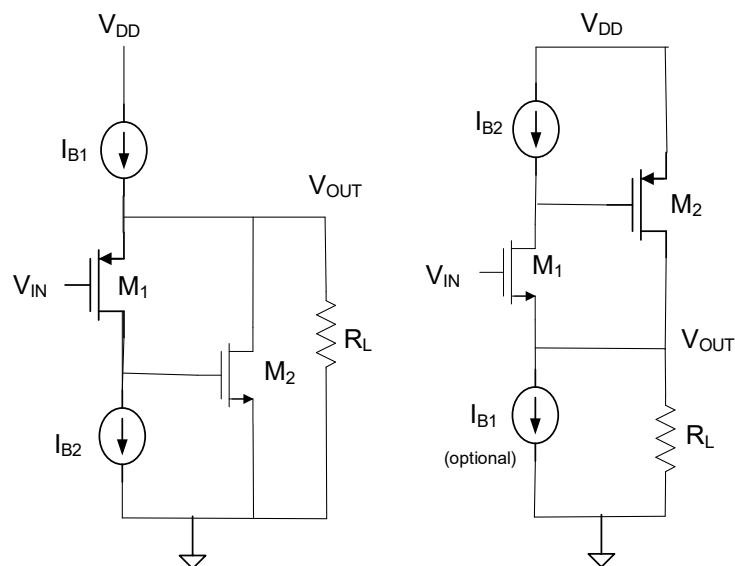
Ideally $V_{OUT} = V_{IN}$

Assume load terminated on gnd

Current through M_1 changes with V_{IN}

Voltage shift varies with V_{IN} in buffer

Super Buffer



Ideally $V_{OUT} = V_{IN}$

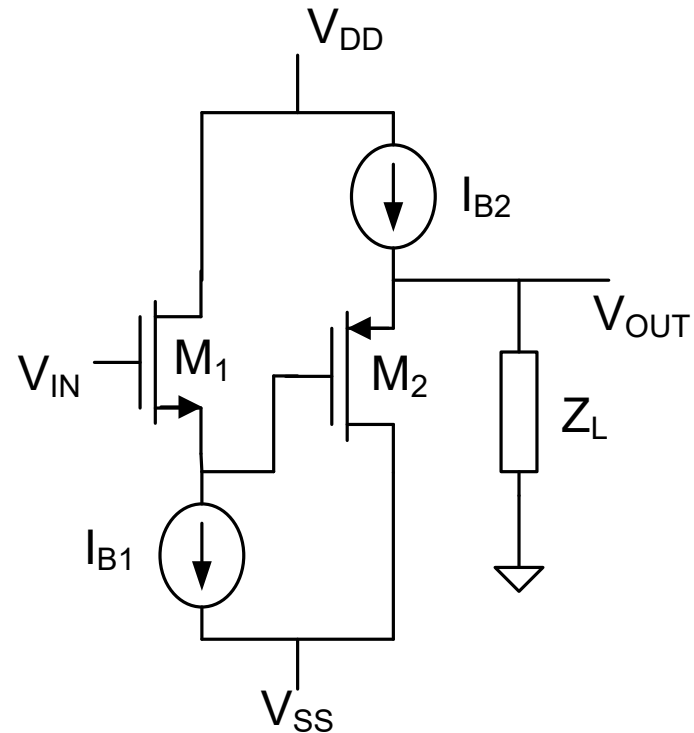
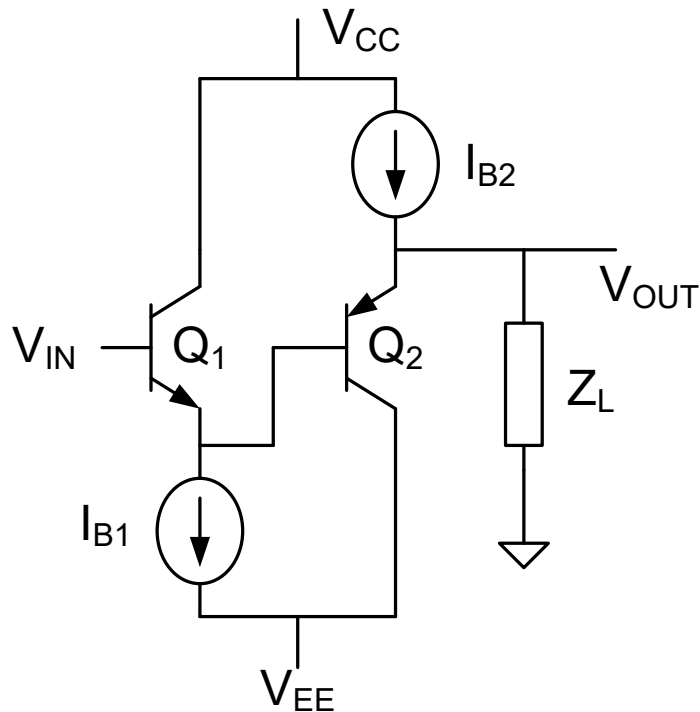
Assume load terminated on gnd

Current through shift transistor is constant for Super Buffer as V_{IN} changes so voltage shift does not change with V_{IN}

Same nominal voltage shift as buffer

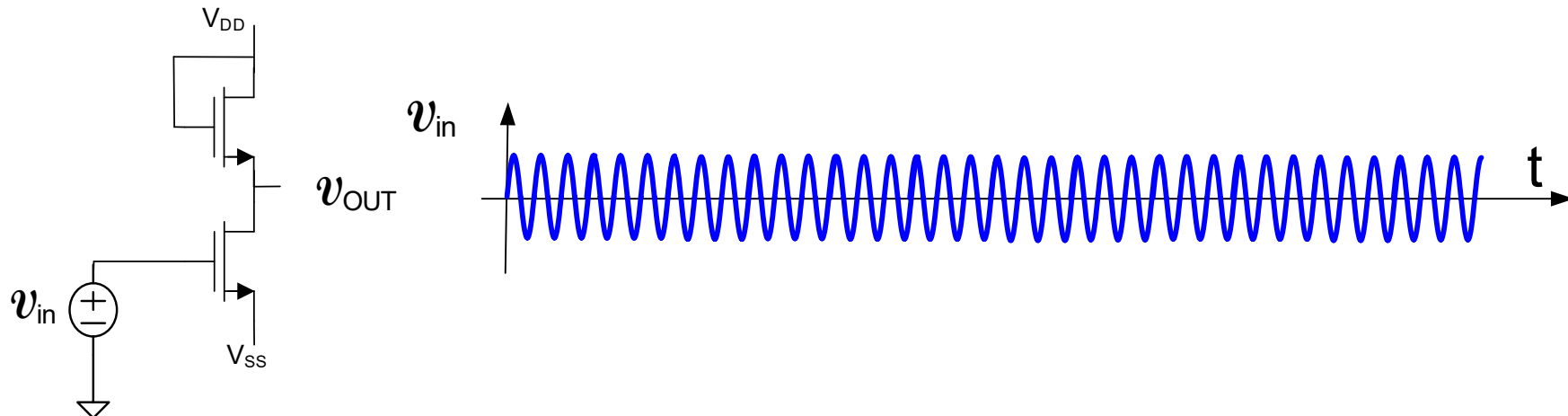
Other Basic Configurations

Low offset buffers



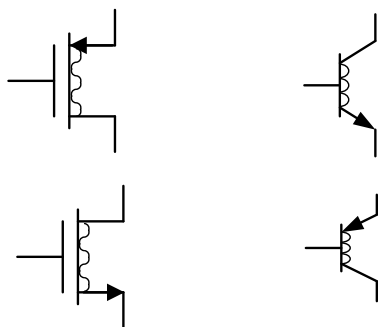
- **Actually a CC-CC or a CD-CD cascade**
- **Significant drop in offset between input and output**
- **Biasing with DC current sources**
- **Can Add Super Buffer to Output**

High Frequency Amplifier Performance



Parasitic capacitors in the MOS transistors will limit the high frequency performance

How can we predict performance of amplifiers (with small-signal inputs) at high frequencies?



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High Frequency
MOSFET Model

Types of Capacitors in MOSFETs

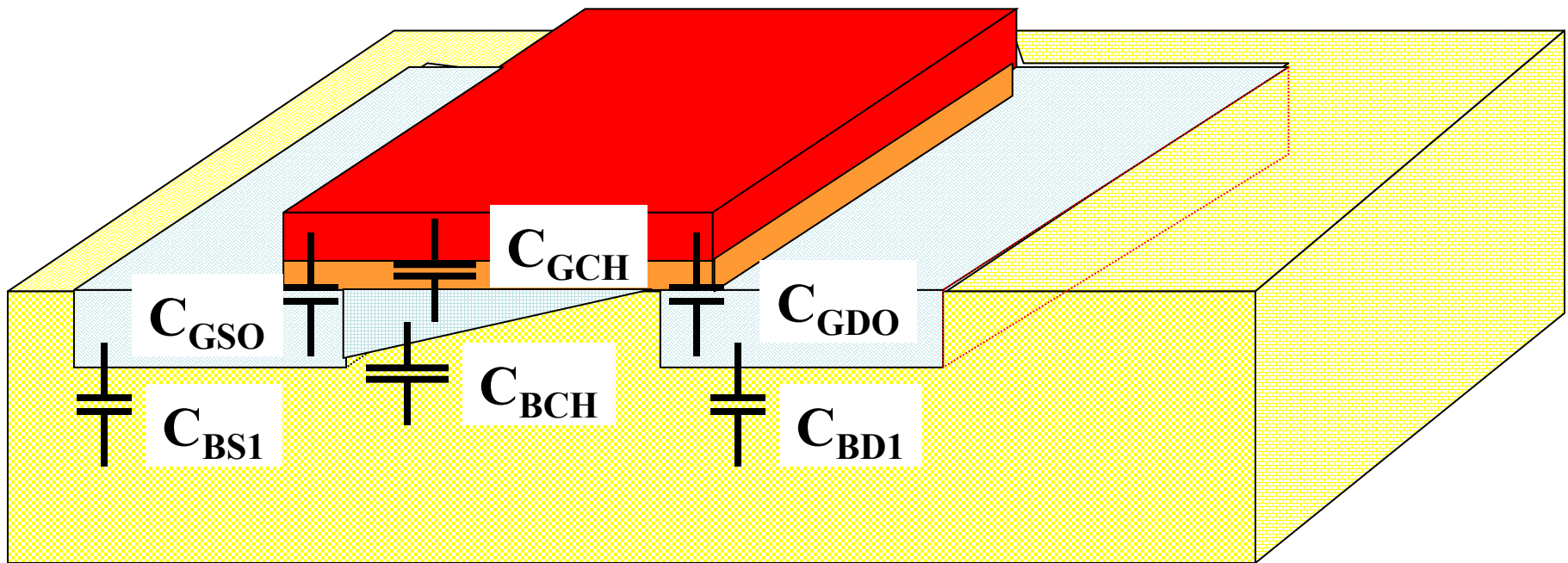
1. Fixed Capacitors
 - a. Fixed Geometry
 - b. Junction



2. Operating Region Dependent

Parasitic Capacitors in MOSFET

Operation Region Dependent and Fixed --Saturation



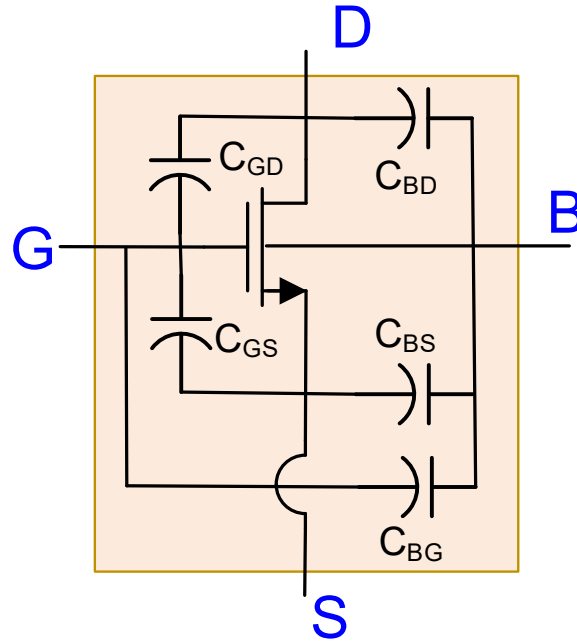
Overlap Capacitors: C_{GDO} , C_{GSO}

Junction Capacitors: C_{BS1} , C_{BD1}

Saturation Capacitors: C_{GCH} , C_{BCH}

- $2/3 C_{OX}WL$ is often attributed to C_{GCH} to account for LD and saturation
- This approximation is reasonable for minimum-length devices but not so good for longer devices

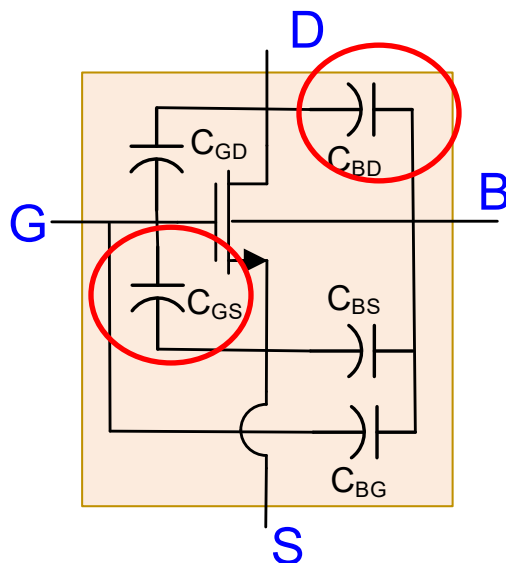
Parasitic Capacitance Summary



	Cutoff	Ohmic	Saturation
C_{GS}	$C_{ox}W L_D$	$0.5C_{ox}WL$	$C_{ox}W L_D + (2/3)C_{ox}WL$
C_{GD}	$C_{ox}W L_D$	$0.5C_{ox}WL$	$C_{ox}W L_D$
C_{BG}	$C_{ox}WL$ (or less)	0	0
C_{BS}	$C_{BOT}A_S + C_{SW}P_S$	$C_{BOT}A_S + C_{SW}P_S + 0.5WLC_{BOTCH}$	$C_{BOT}A_S + C_{SW}P_S + (2/3)WLC_{BOTCH}$
C_{BD}	$C_{BOT}A_D + C_{SW}P_D$	$C_{BOT}A_D + C_{SW}P_D + 0.5WLC_{BOTCH}$	$C_{BOT}A_D + C_{SW}P_D$

Observe there is no C_{DS} in this model because does not physically exist

Parasitic Capacitance Implications



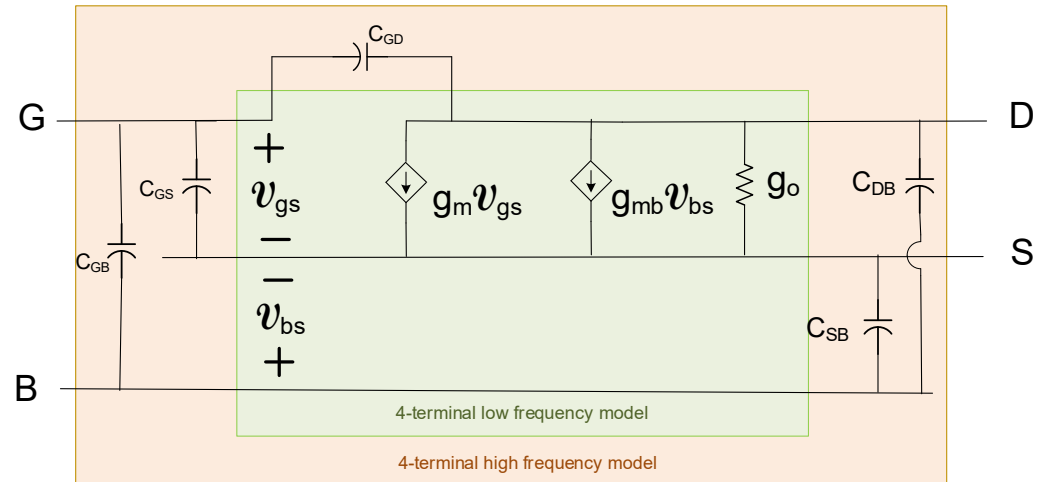
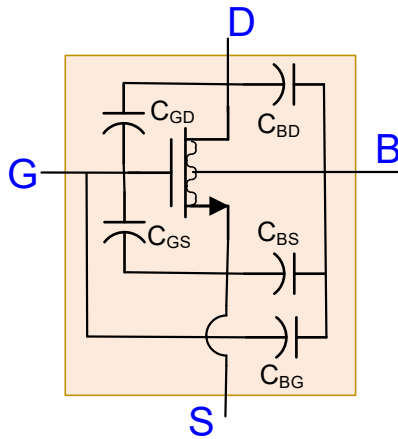
The parasitic capacitances inherently introduce an upper limit on how fast either digital circuits or analog circuits can operate in a given process

Two parameters, f_{MAX} and f_T , (not defined yet) are two metrics that are used to specify the fundamental speed limit in a semiconductor process

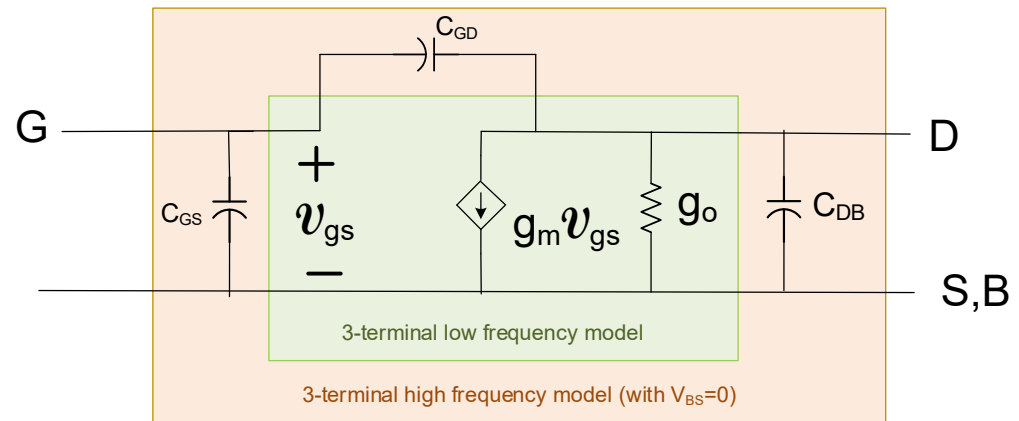
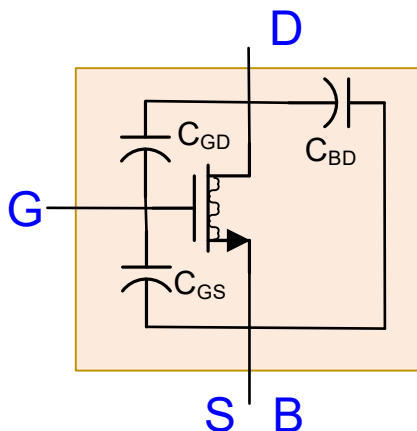
The dominant parasitic capacitances for most circuits are C_{GS} and C_{BD}

High Frequency Small-Signal Model

(Saturation Region)

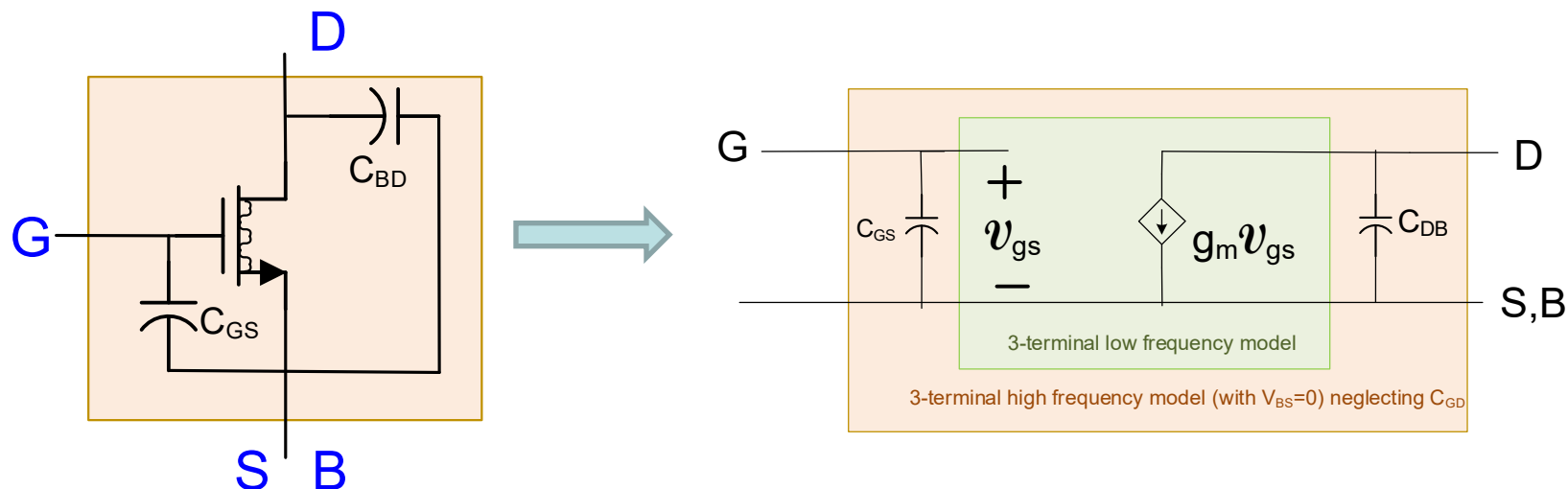


Often $V_{BS}=0$ and $C_{BG}=0$, so simplifies to



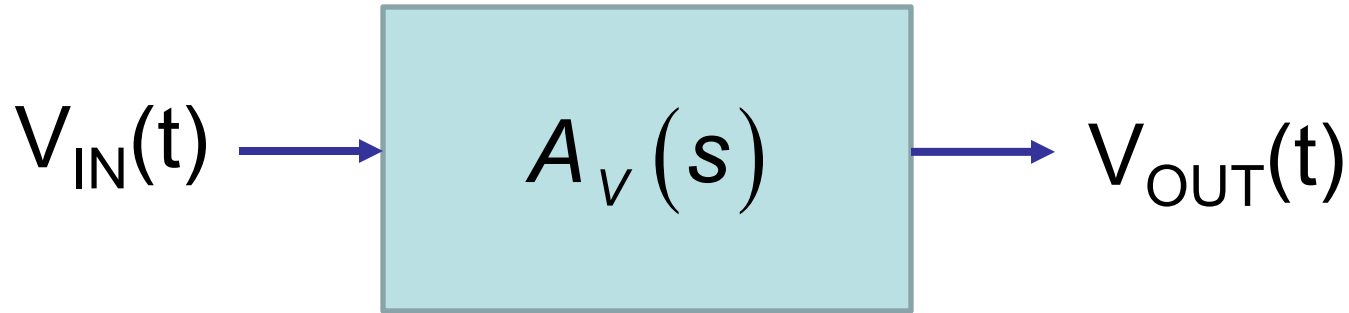
High Frequency Small-Signal Model

Often $V_{BS}=0$ and $C_{BG}=0$ and C_{GD} and g_0 can be neglected so simplifies farther to



Neglecting C_{GD} which is high frequency feedback from output to input often simplifies analysis considerably

Sinusoidal Steady State Response for Linear Systems



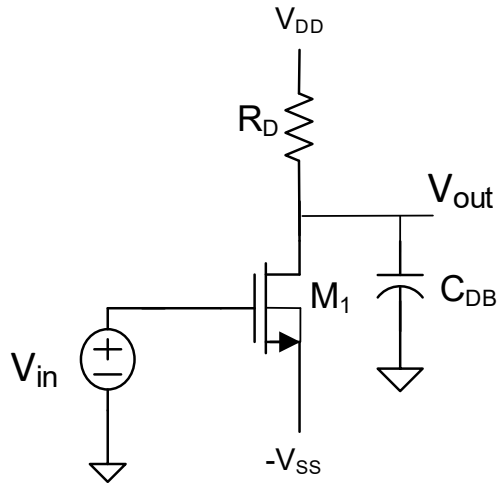
Key Result from EE 201

If $V_{IN} = V_m \sin(\omega t + \theta)$ where V_m is small (so linear operation maintained)

Steady state output is also a sinusoid given by

$$V_{OUT}(t) = V_m |A_V(j\omega)| \sin(\omega t + \theta + \angle A_V(j\omega))$$

Sinusoidal Steady State Response for Linear Systems



$$|A_V(j\omega)| = \frac{g_{m1}R_D}{\sqrt{(\omega C_{DB}R_D)^2 + 1}}$$
$$\angle A_V(j\omega) = -180^\circ - \tan^{-1}\left(\frac{\omega C_{DB}R_D}{1}\right)$$

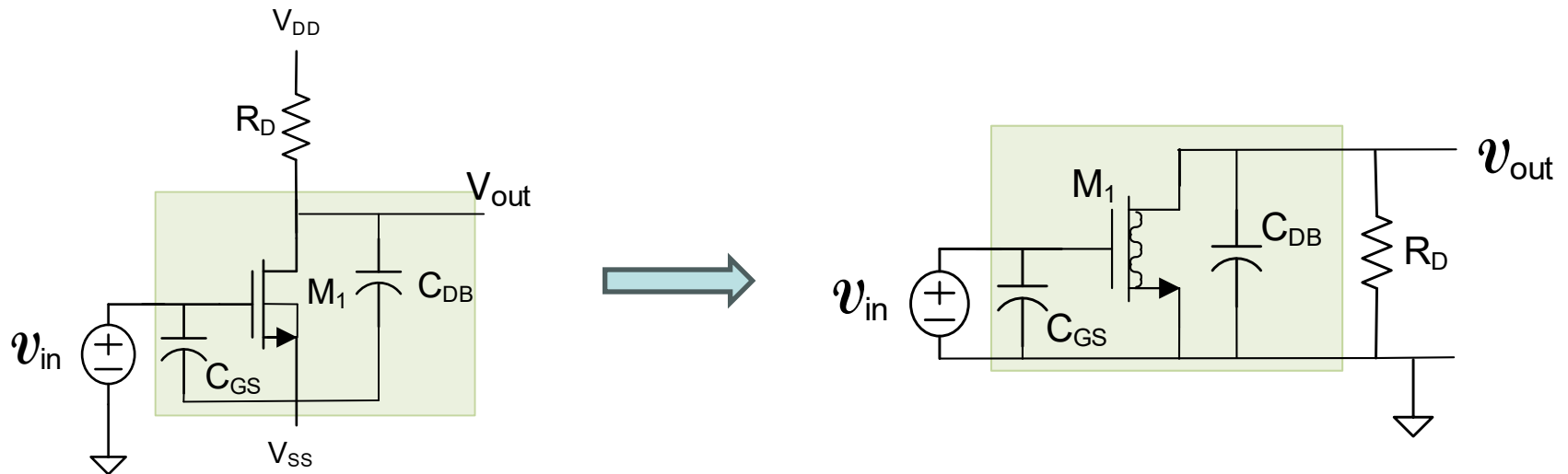
If $V_{IN} = V_m \sin(\omega t + \theta)$

For V_m small, small-signal steady state output given by

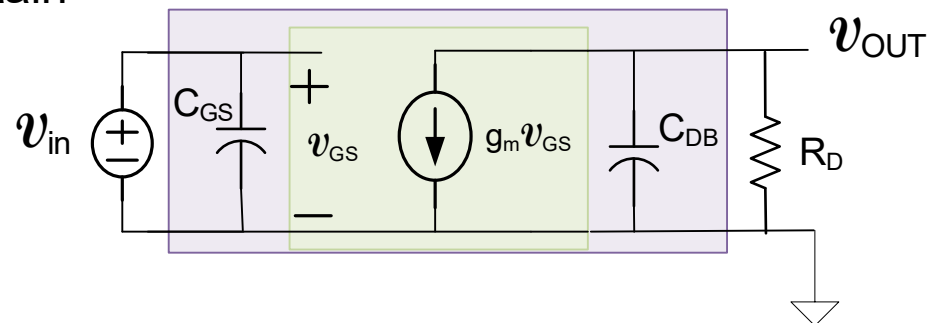
$$V_{OUT}(t) = V_m \frac{g_{m1}R_D}{\sqrt{(\omega C_{DB}R_D)^2 + 1}} \sin\left(\omega t + \theta - 180^\circ - \tan^{-1}\left(\frac{\omega C_{DB}R_D}{1}\right)\right)$$

How fast can amplifiers operate in a given process?

Consider the basic CS amplifier and only the dominant capacitive parasitics C_{GS} and C_{DB}

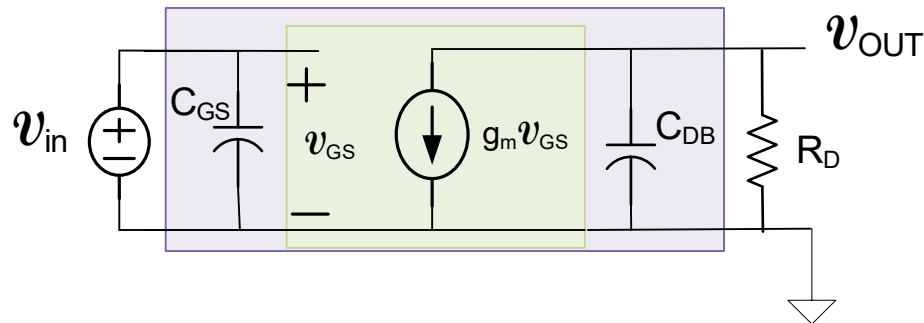


Neglecting g_o , obtain



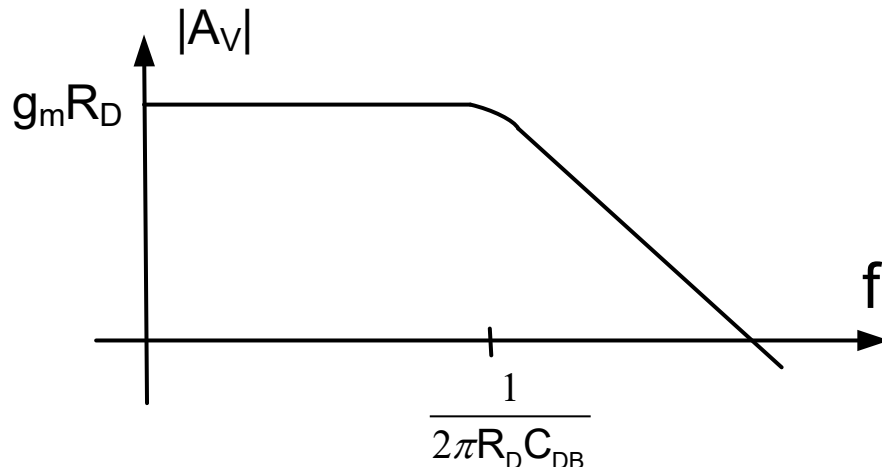
How fast can amplifiers operate in a given process?

Consider the basic CS amplifier and only the dominant capacitive parasitics C_{GS} and C_{DB}



$$v_{OUT} (G_D + sC_{DB}) + g_m v_{in} = 0 \quad \Rightarrow \quad \frac{v_{OUT}}{v_{in}} = -\frac{g_m}{G_D + sC_{DB}} = -\frac{g_m R_D}{1 + sR_D C_{DB}}$$

$$|A_V| = \left| \frac{v_{OUT}}{v_{in}} \right| = \left| \frac{g_m R_D}{1 + j\omega R_D C_{DB}} \right| = \frac{g_m R_D}{\sqrt{1 + (\omega R_D C_{DB})^2}}$$



$$\omega = 2\pi f$$

For any R_D and any transistor, with this model gain will go to 0 at high frequencies

How fast can amplifiers operate in a given process?

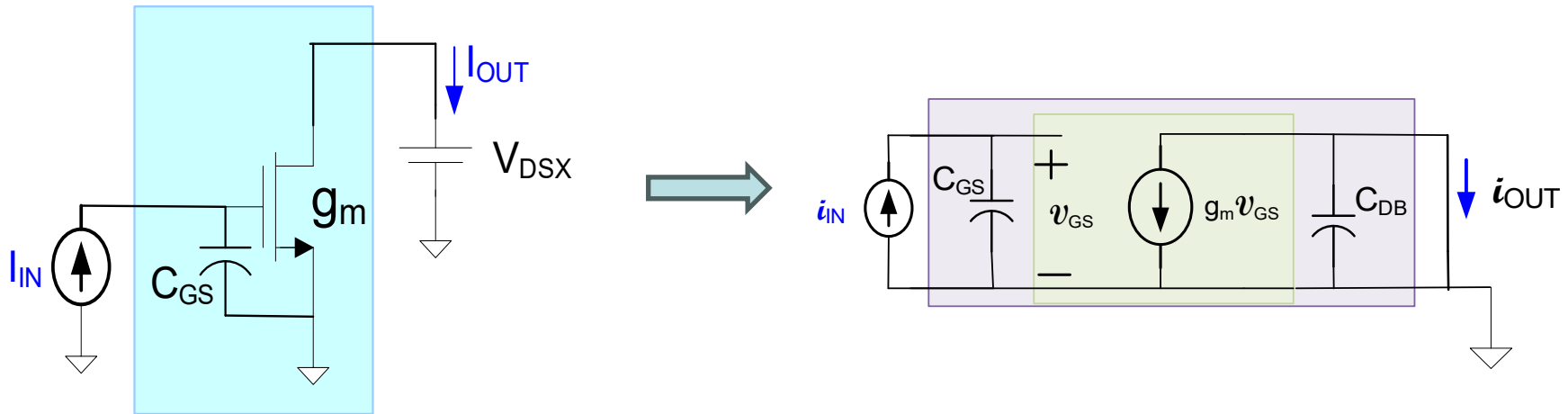
f_T and f_{MAX} for a semiconductor process

f_T is defined to be the frequency where the short-circuit current gain of a transistor drops to unity

f_{MAX} is defined to be the frequency where the power gain of the transistor drops to unity (related to the maximum frequency of oscillation in a process)

Transition (transit) frequency (f_T) of a process

The transit frequency of a process is the frequency where the short-circuit current gain of the common-source configuration drops to 1.



$$\left. \begin{aligned} i_{OUT} &= -g_m v_{gs} \\ i_{IN} \cdot \frac{1}{sC_{GS}} &= v_{gs} \end{aligned} \right\}$$

$$\frac{i_{OUT}}{i_{IN}} = -\frac{g_m}{sC_{GS}}$$

$$1 = \frac{g_m}{C_{GS} \omega_T}$$

$$\omega_T = \frac{g_m}{C_{GS}} = \frac{\left(\mu C_{OX} \frac{W}{L} V_{EB} \right)}{\frac{2}{3} C_{OX} WL} = \frac{3}{2} \frac{\mu V_{EB}}{L^2}$$

$$\omega_T = \frac{3}{2} \frac{\mu V_{EB}}{L_{min}^2}$$

f_T and f_{MAX} for a semiconductor process

f_T is defined to be the frequency where the short-circuit current gain of a transistor drops to unity

f_{MAX} is defined to be the frequency where the power gain of the transistor drops to unity (related to the maximum frequency of oscillation in a process)

$$\omega_T = \frac{3}{2} \frac{\mu V_{EB}}{L_{min}^2}$$

Assuming $L_{MIN} = 2\lambda - 2 \bullet LD \implies f_T \simeq \frac{3}{4\pi} \frac{\mu V_{EB}}{L_{min}^2} = \frac{3}{16\pi} \frac{\mu |V_{DD} - V_{TH}|}{(\lambda - LD)^2}$

f_T strongly dependent on V_{EB}

for the ON 0.5u process

$$\left. \begin{array}{l} u_n C_{OX} = 100 \mu A/V^2 \\ C_{OX} = 2.4 fF/u^2 \\ \lambda = 0.2 \mu \\ LD = .05 \mu \\ V_{THn} = 0.8V \end{array} \right\} \begin{array}{l} u_n = 4E10 A \mu^2 F^{-1} V^{-2} \\ u_n = 400 cm^2 A F^{-1} V^{-2} \end{array}$$

At $V_{EB} = 1V$, $f_T = 25GHz$

Note: As feature sizes shrink with process nodes, V_{EB-MAX} will typically drop linearly but L_{min} will drop quadratically thus f_T gets much larger in small feature processes

f_T and f_{MAX} for a semiconductor process

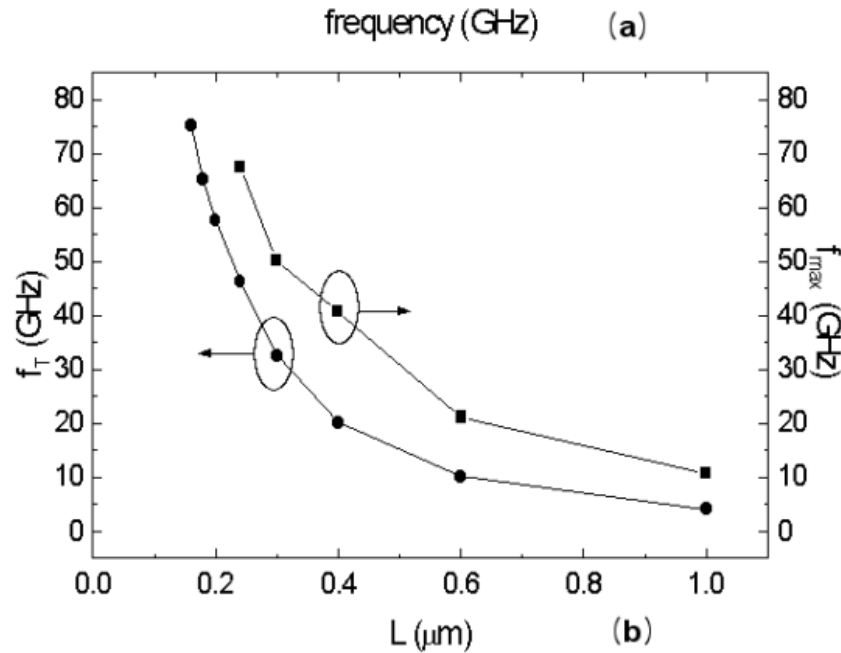


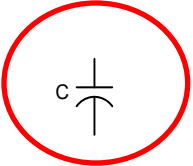











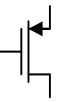
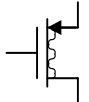
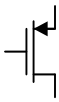


Fig. 7. (a) Maximum stable gain (MSG) and maximum available gain (MAG) for different channel lengths and (b) the cutoff frequency (f_T) and maximum oscillation frequency (f_{max}) as functions of the channel length.

For 0.18u process, $V_D=2V$, $V_G=1.2V$

Recall:

Small-signal and simplified dc equivalent elements

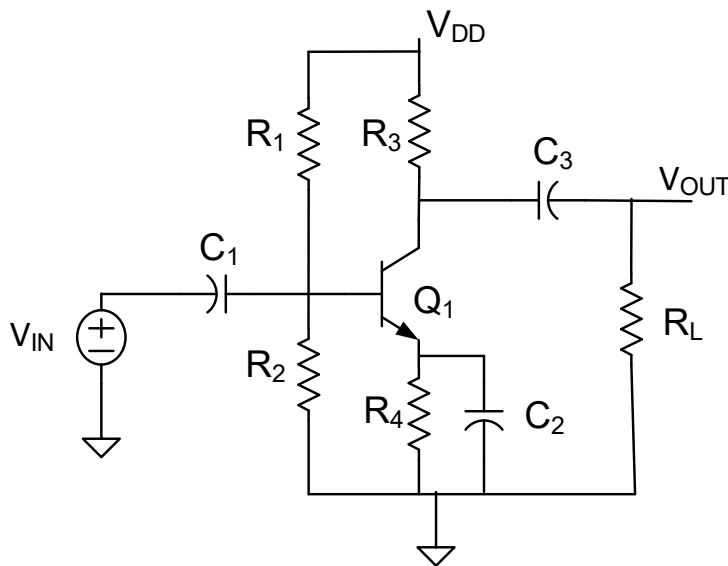
	Element	ss equivalent	Simplified dc equivalent
Capacitors	C Large		
	C Small		
Inductors	L Large		
	L Small		
Diodes			 Simplified
MOS transistors (MOSFET (enhancement or depletion), JFET)			 Simplified
			 Simplified

Have not yet considered situations where the small capacitor (beyond those in the small-signal transistor) is relevant in small-signal analysis

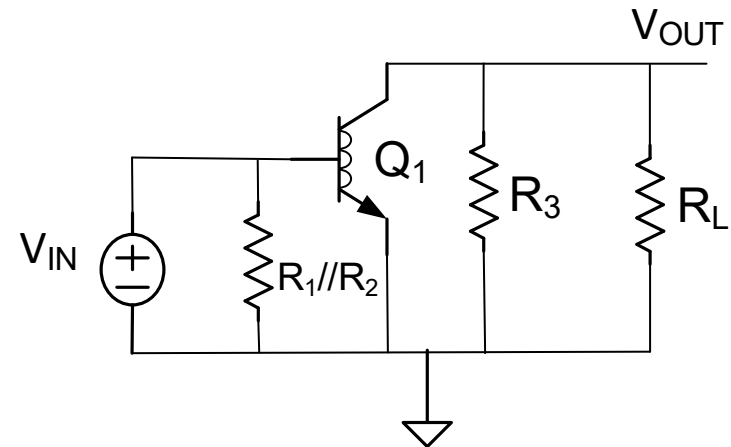
Amplifiers with Small Capacitors

Consider a bipolar amplifier first where C_3 is a small capacitor but not a parasitic capacitor

Recall:



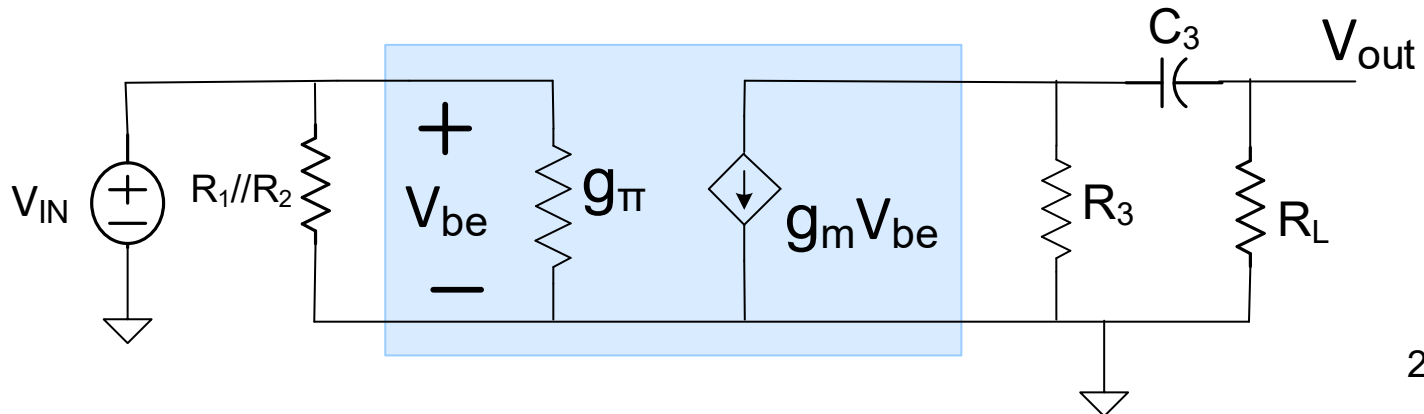
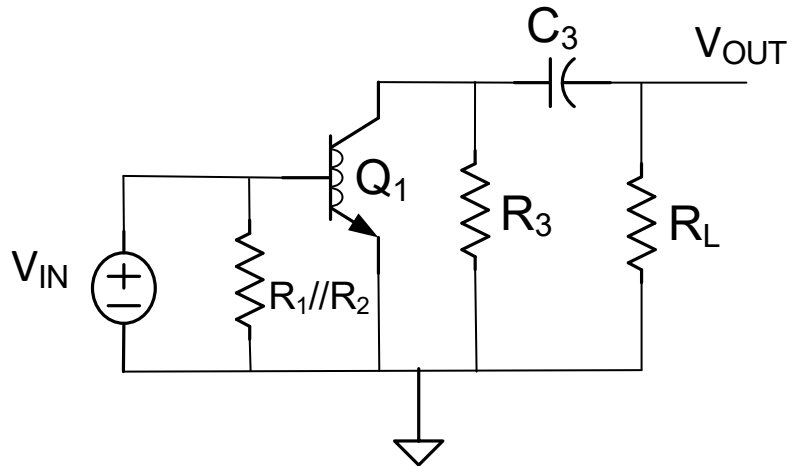
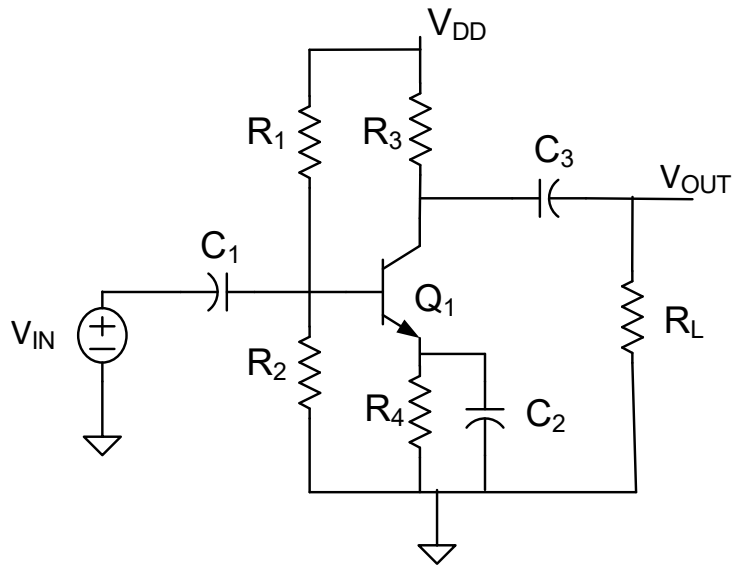
If capacitors are large



$$A_V = -g_{m1} \bullet R_3 // R_L$$

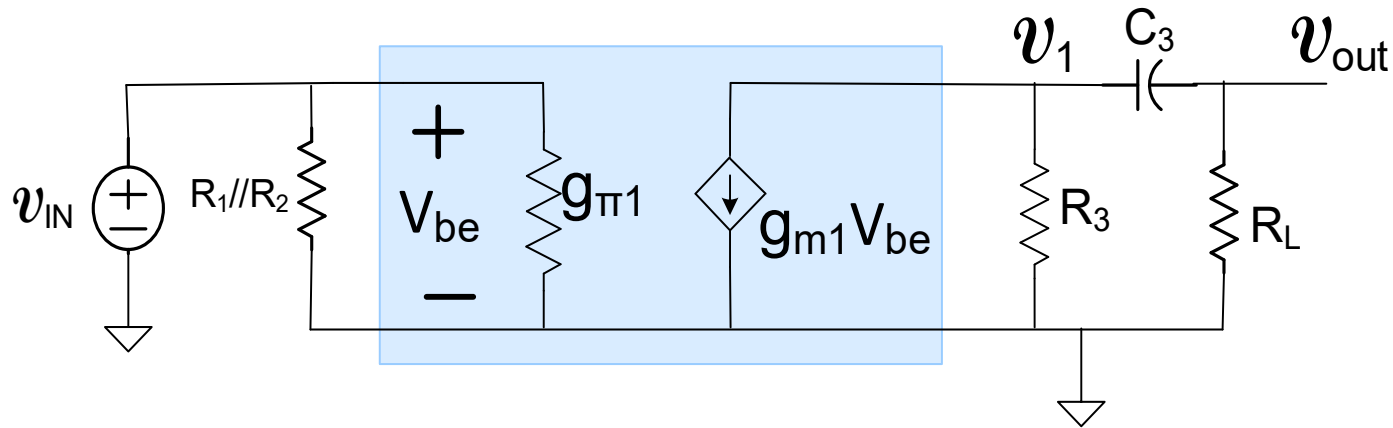
Amplifiers with Small Capacitors

What if C_1 and C_2 large but C_3 is not large?:



Amplifiers with Small Capacitors

What if C_1 and C_2 large but C_3 not large?:



From KCL:

$$\left. \begin{aligned} v_{OUT} (sC_3 + G_L) &= v_1 sC_3 \\ v_1 (sC_3 + G_3) + g_{m1} v_{IN} &= v_{OUT} sC_3 \end{aligned} \right\}$$

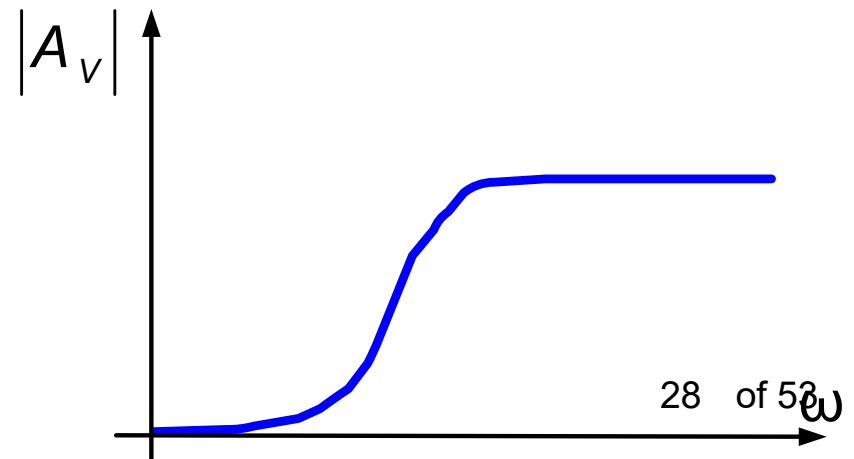
Solving:

$$\frac{v_{OUT}}{v_{IN}} = - \frac{-sC_3 g_{m1}}{sC_3 (G_L + G_3) + G_3 G_L}$$

Equivalently:

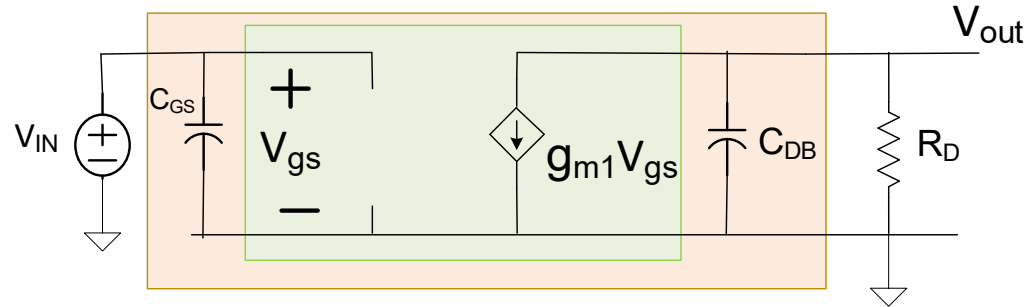
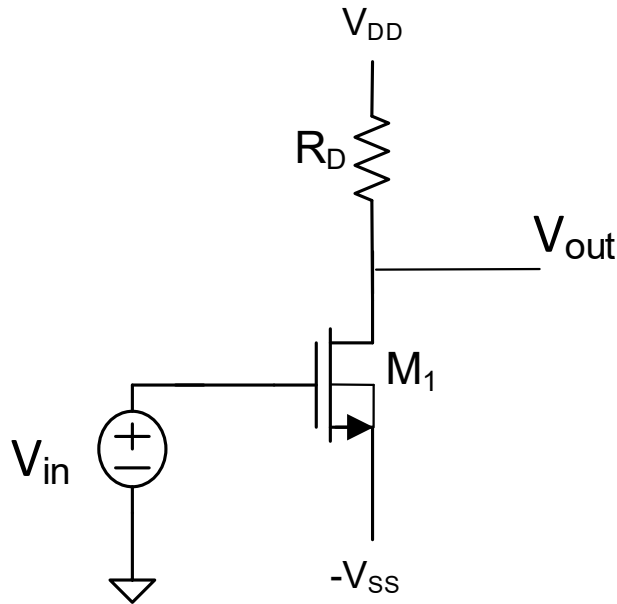
$$\frac{v_{OUT}}{v_{IN}} = - \frac{g_{m1} sC_3 R_3 R_L}{sC_3 (R_L + R_3) + 1}$$

Serves as a first-order high-pass filter



Amplifiers with Small Capacitors

Consider again the effects of the parasitics C_{GS} and C_{DB} in a bit more detail



By KCL:

$$v_{OUT} (sC_{DB} + G_D) = -g_{m1} v_{IN}$$

Solving:

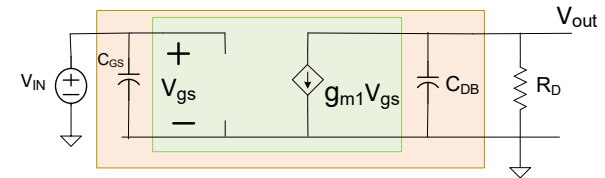
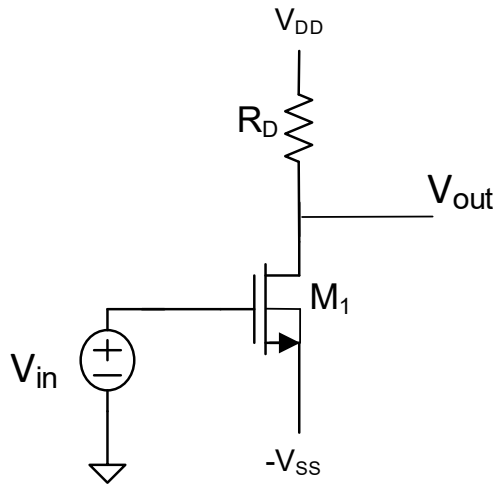
$$\frac{v_{OUT}}{v_{IN}} = -\frac{g_{m1}}{sC_{DB} + G_D}$$

Equivalently:

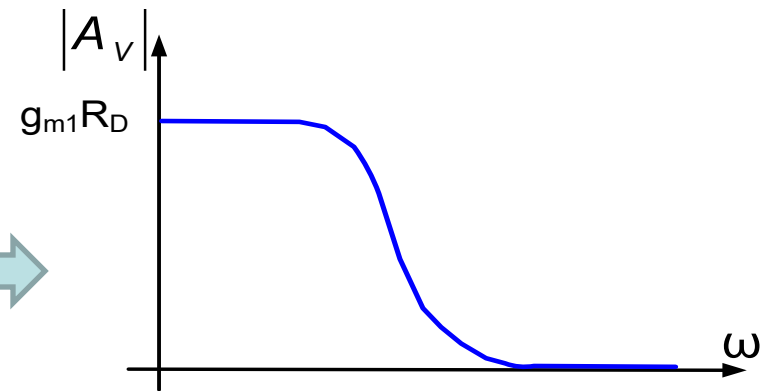
$$\frac{v_{OUT}}{v_{IN}} = \frac{-g_{m1} R_D}{sC_{DB} R_D + 1}$$

Amplifiers with Small Capacitors

Consider parasitic C_{GS} and C_{DB}



$$\frac{v_{OUT}}{v_{IN}} = A_V(s) = -\frac{g_{m1}R_D}{sC_{DB}R_D + 1}$$



Since first-order low-pass, half-power frequency given by

$$\omega_{3dB} = \frac{1}{R_D C_{DB}}$$

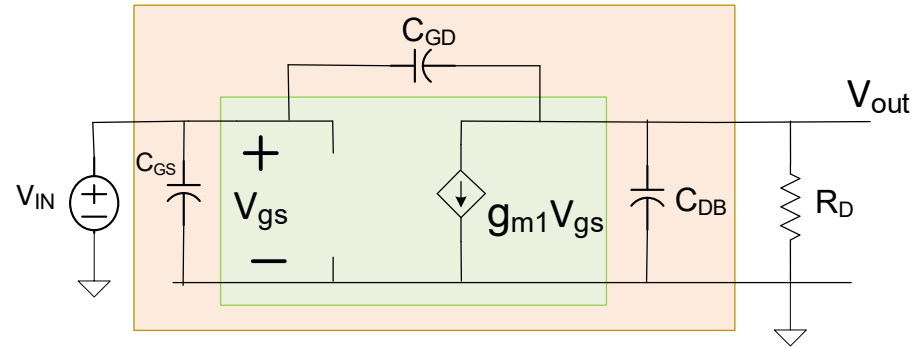
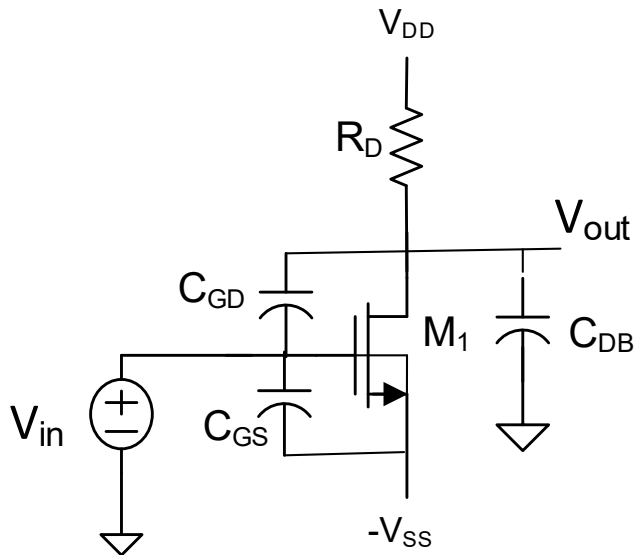
$$A_V(j\omega) = \frac{-g_{m1}R_D}{j\omega C_{DB}R_D + 1}$$

$$|A_V(j\omega)| = \frac{g_{m1}R_D}{\sqrt{(\omega C_{DB}R_D)^2 + 1}}$$

$$\angle A_V(j\omega) = -180^\circ - \tan^{-1}\left(\frac{\omega C_{DB}R_D}{1}\right)$$

Amplifiers with Small Capacitors

Consider also the parasitic C_{GD} (along with C_{GS} and C_{DB})



By KCL:

$$v_{OUT} (s[C_{DB} + C_{GD}] + G_D) = -g_{m1}v_{IN} + sC_{GD}v_{IN}$$

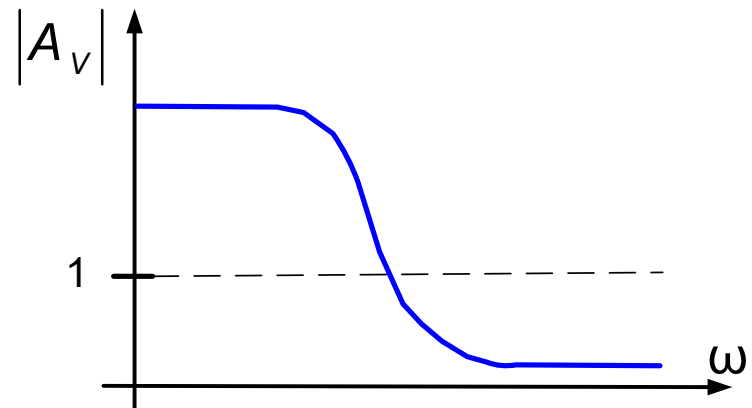
C_{DB} causes gain to decrease at high frequencies
 C_{GD} causes feed-forward and limits high frequency drop
 Has one LHP pole and one RHP zero

Solving:

$$\frac{v_{OUT}}{v_{IN}} = -\frac{-g_{m1} + sC_{GD}}{s[C_{DB} + C_{GD}] + G_D}$$

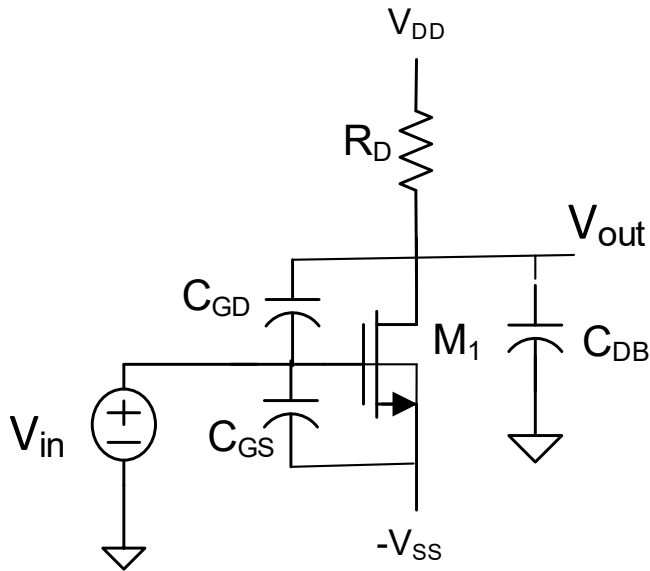
Equivalently:

$$\frac{v_{OUT}}{v_{IN}} = -\frac{-R_D(g_{m1} - sC_{GD})}{s[C_{DB} + C_{GD}]R_D + 1}$$



Amplifiers with Small Capacitors

Effects of parasitics C_{GS} , C_{GD} , and C_{DB}



Device parasitics problematic at high frequencies

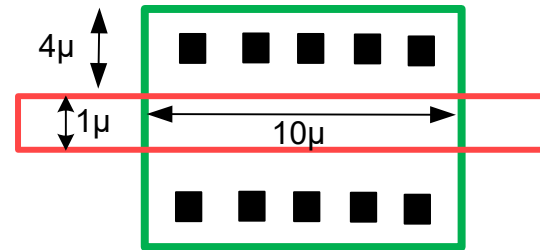
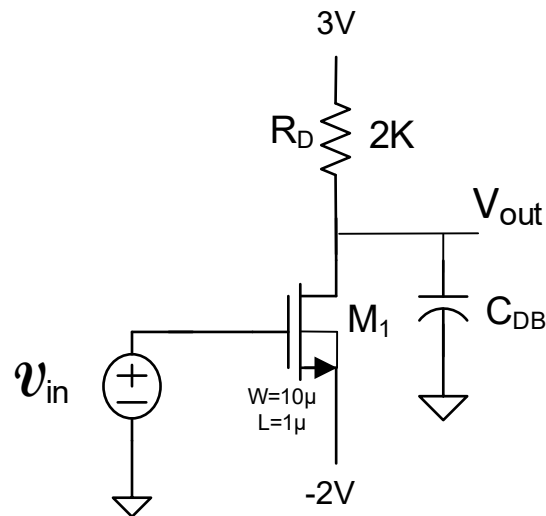
C_{DB} , C_{GD} and C_{GS} effects can be significant

Value of parasitic capacitances strongly dependent upon layout

Device parasitics usually not a problem at audio frequencies

Causes gain to decrease at high frequencies:
has one high frequency LHP pole and one high frequency RHP zero.

Example: Determine the small-signal voltage gain and the 3dB bandwidth. Consider only the effects of C_{DB} on the BW. Assume a 0.5u process with $V_{TH}=0.75V$ and the layout of the transistor shown.



From PDK

$$C_{DB} = C_{BOT} * 40u^2 + C_{SW} * 28u$$

$$C_{BOT} = 942aF/u^2 \quad C_{SW} = 212aF/u$$

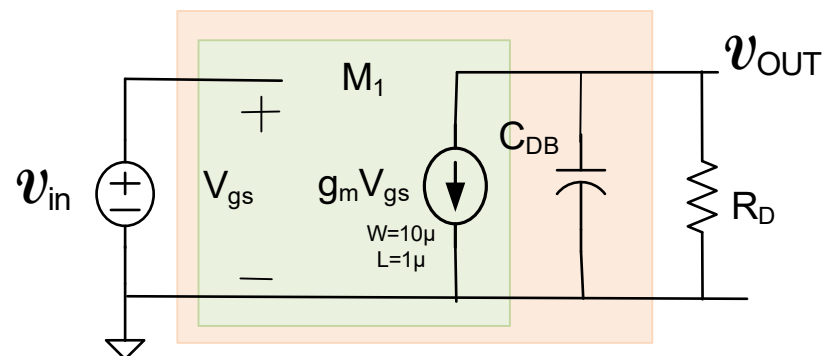
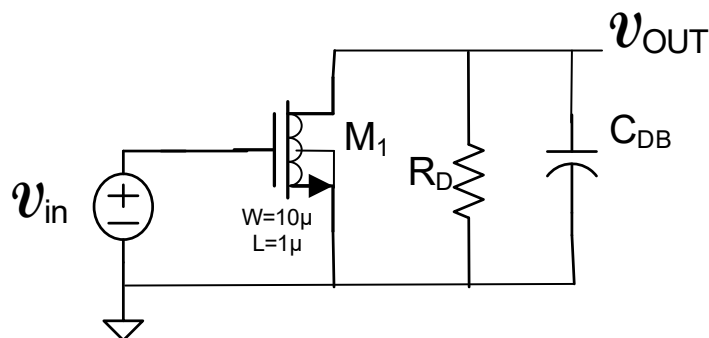
$$C_{DB} = 942aF/u^2 * 40u^2 + 212aF/u * 28u$$

$$C_{DB} = 37.7fF + 5.9fF = 43.6fF$$

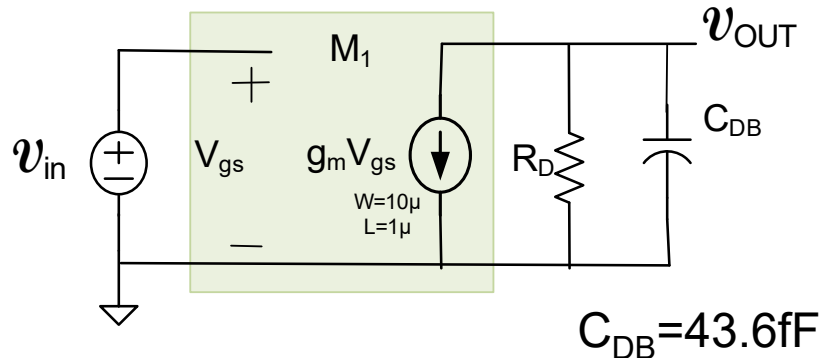
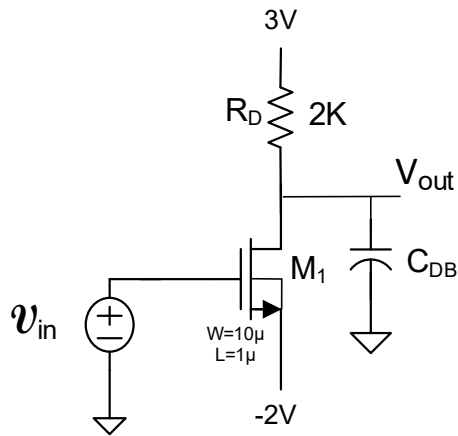
Solution:

$$I_{DQ} = 100\mu A / V^2 \frac{10}{2 \cdot 1} (2 - 0.75)^2 = 0.78mA$$

$$I_{DQ} R_D = 0.78mA \cdot 2K = 1.56$$



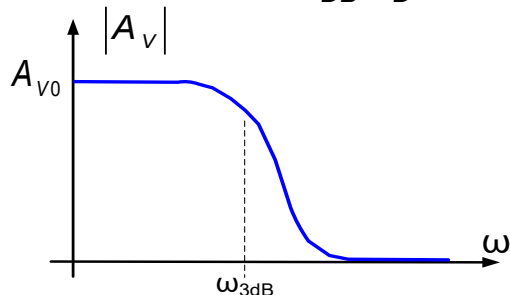
Example: Determine the small-signal dc voltage gain and the 3dB bandwidth. Consider only the effects of C_{DB} on the BW. Assume a 0.5u process with $V_{TH}=0.75V$ and the layout of the transistor shown.



Solution continued:

$$v_{OUT} (G_D + sC_{DB}) + g_m v_{IN} = 0$$

$$v_{OUT} = -v_{IN} \frac{g_m R_D}{1 + sC_{DB} R_D}$$

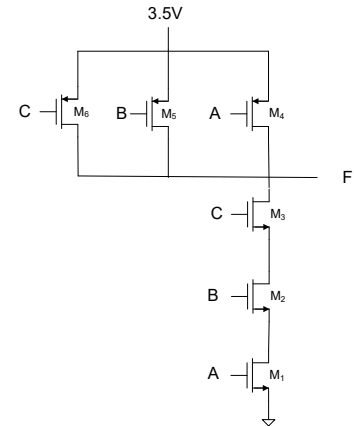
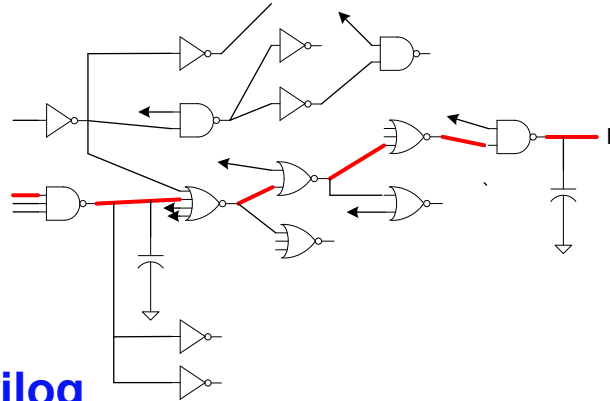
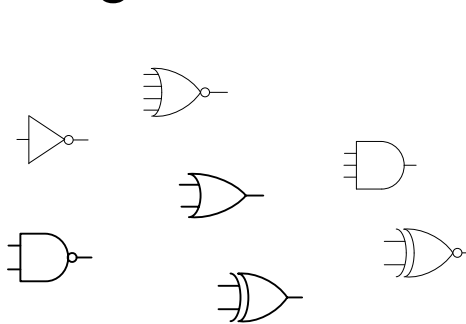


$$A_{V0} = -g_m R_D = -\frac{2I_{DQ} R_D}{V_{EB}} = -\frac{3.12}{1.25} = -2.5$$

$$f_{3dB} = \frac{1}{2\pi} \cdot \frac{1}{R_D C_{DB}} = 1.8GHz$$

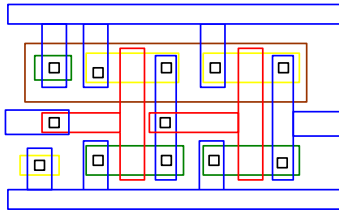
Digital Circuit Design

Most of the remainder of the course will be devoted to digital circuit design



Verilog

VHDL



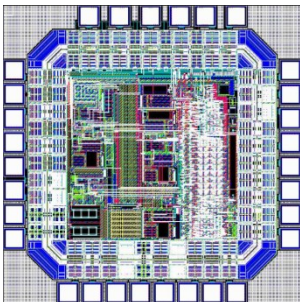
```
module gates (input logic [3:0] a,b,
              output logic [3:0] y1,y2,y3,y4,y5);
  assign y1 = a&b; //AND
  assign y2 = a | b; //OR
  assign y3 = a ^ b; //XOR
  assign y4 = ~(a & b); //NAND
  assign y5 = ~( a | b); //NOR
endmodule
```

```
library IEEE; use IEEE.STD_LOGIC_1164.all;
```

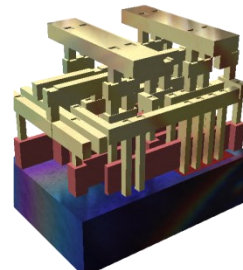
```
entity gates is
  port(a,b: in STD_LOGIC_VECTOR(3 downto 0);
        y1,y2,y3,y4,y5:out STD_LOGIC_VECTOR(3 downto 0));
end;
```

```
architecture synth of gates is
begin
```

```
y1 <= a and b;
y2 <= a or b;
y3 <= a xor b;
y4 <= a nand b;
y5 <= a nor b;
end;
```

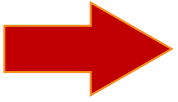


A rendering of a small standard cell with three metal layers (dielectric has been removed). The sand-colored structures are metal interconnect, with the vertical pillars being contacts, typically plugs of tungsten. The reddish structures are polysilicon gates, and the solid at the bottom is the crystalline silicon bulk.



Standard Cell Library

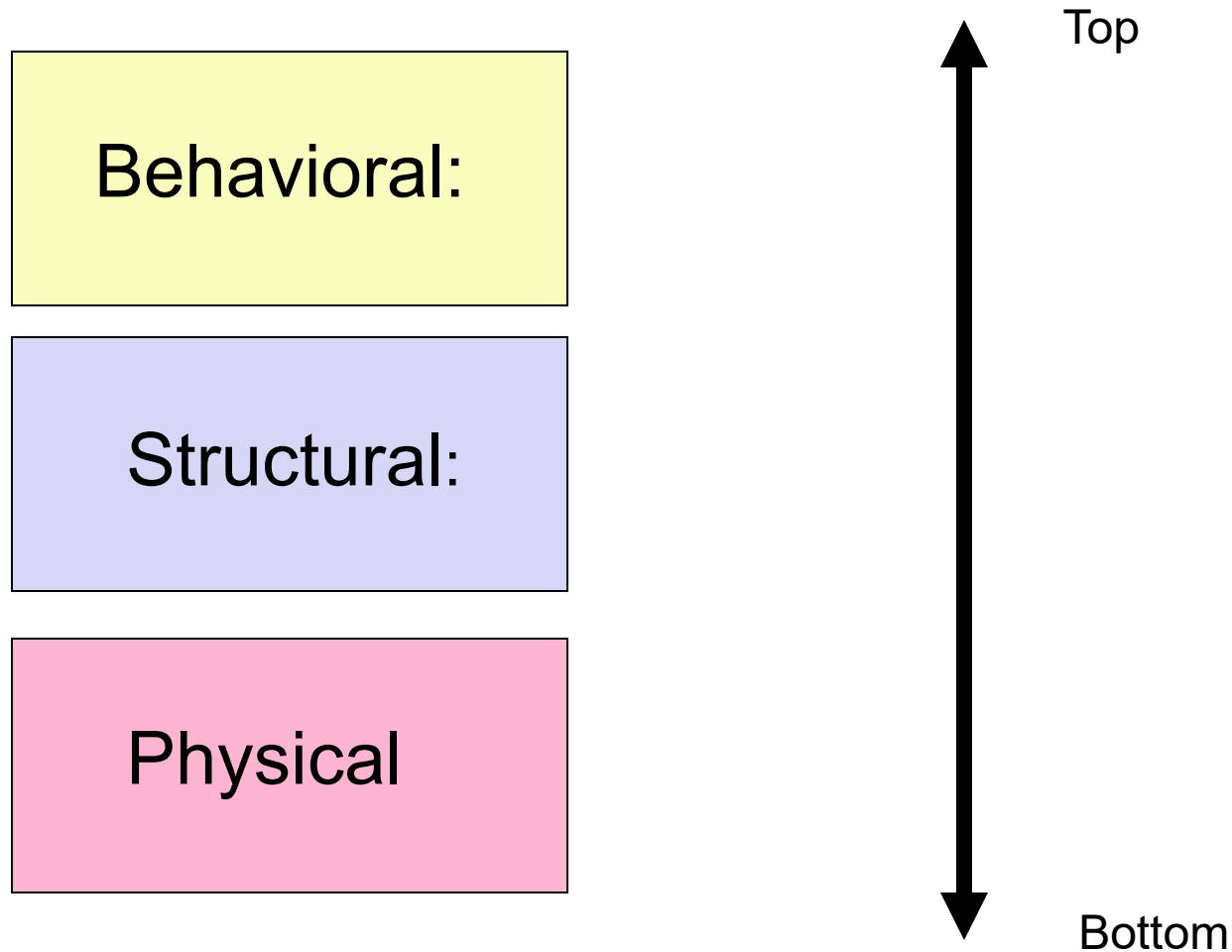
Digital Circuit Design



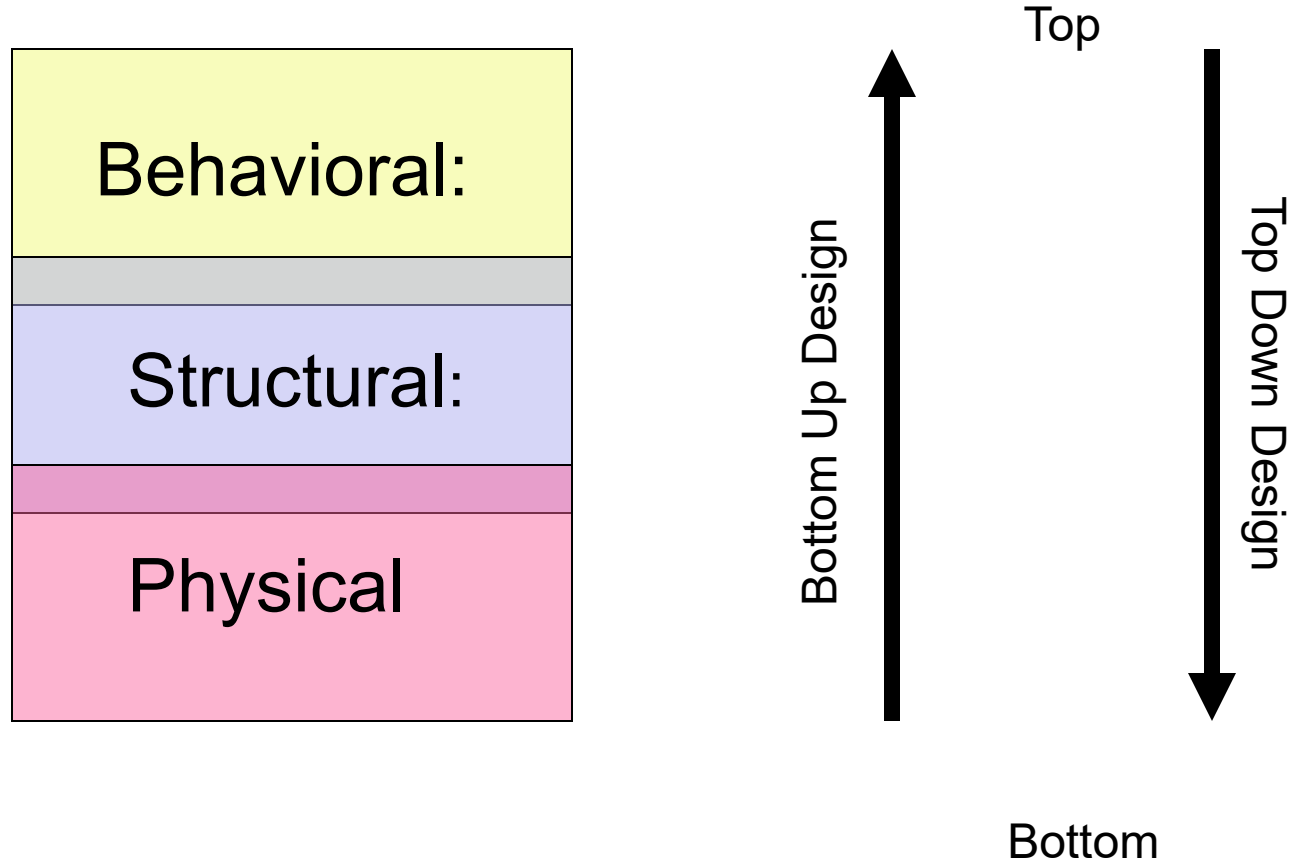
Hierarchical Design

- Basic Logic Gates
 - Properties of Logic Families
 - Characterization of CMOS Inverter
 - Static CMOS Logic Gates
 - Ratio Logic
 - Propagation Delay
 - Simple analytical models
 - FI/OD
 - Logical Effort
 - Elmore Delay
 - Sizing of Gates
 - The Reference Inverter
- Propagation Delay with Multiple Levels of Logic
 - Optimal driving of Large Capacitive Loads
 - Power Dissipation in Logic Circuits
 - Other Logic Styles
 - Array Logic
 - Ring Oscillators

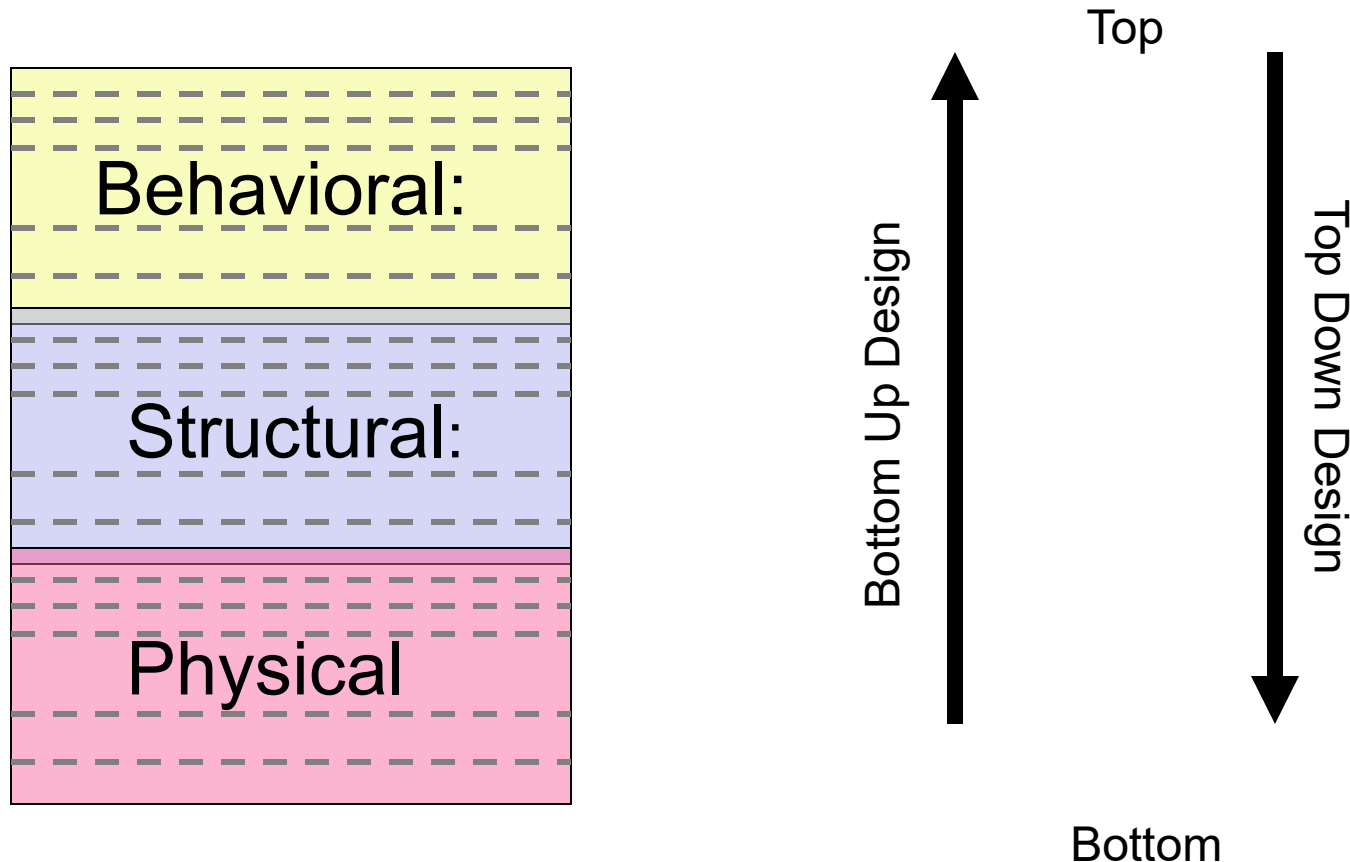
Hierarchical Digital Design Domains:



Hierarchical Digital Design Domains:



Hierarchical Digital Design Domains:



Multiple Sublevels in Each Major Level

All Design Steps may not Fit Naturally in this Description

Hierarchical Digital Design Domains:

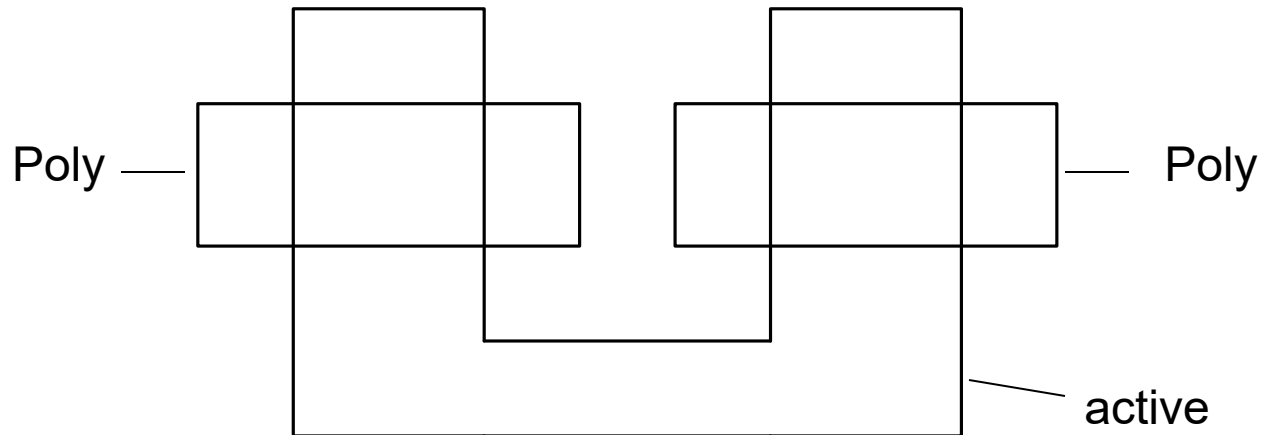
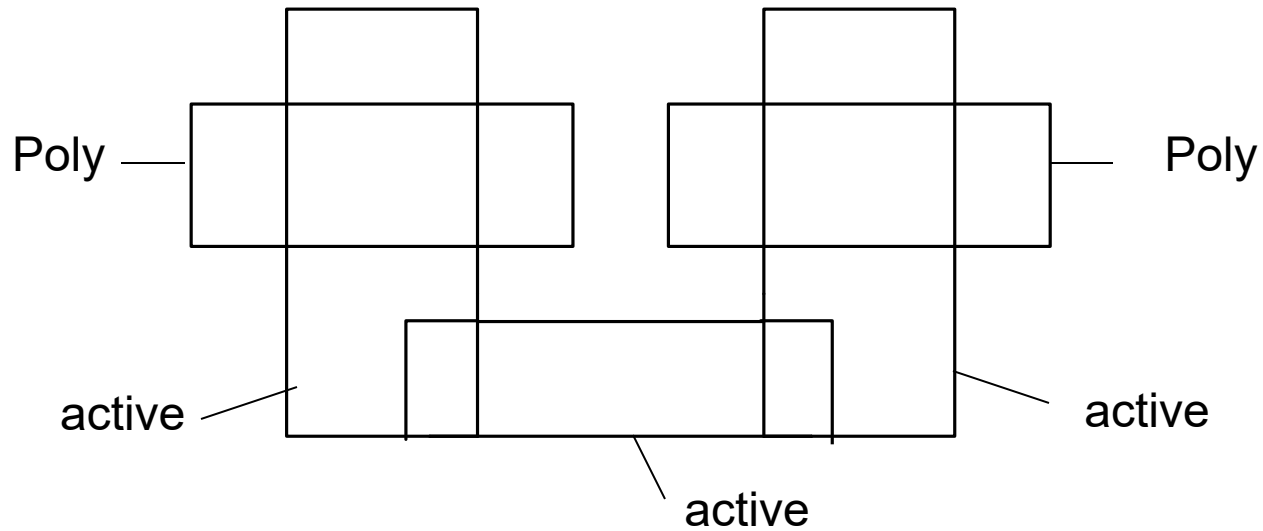
Behavioral : Describes what a system does or what it should do

Structural : Identifies constituent blocks and describes how these blocks are interconnected and how they interact

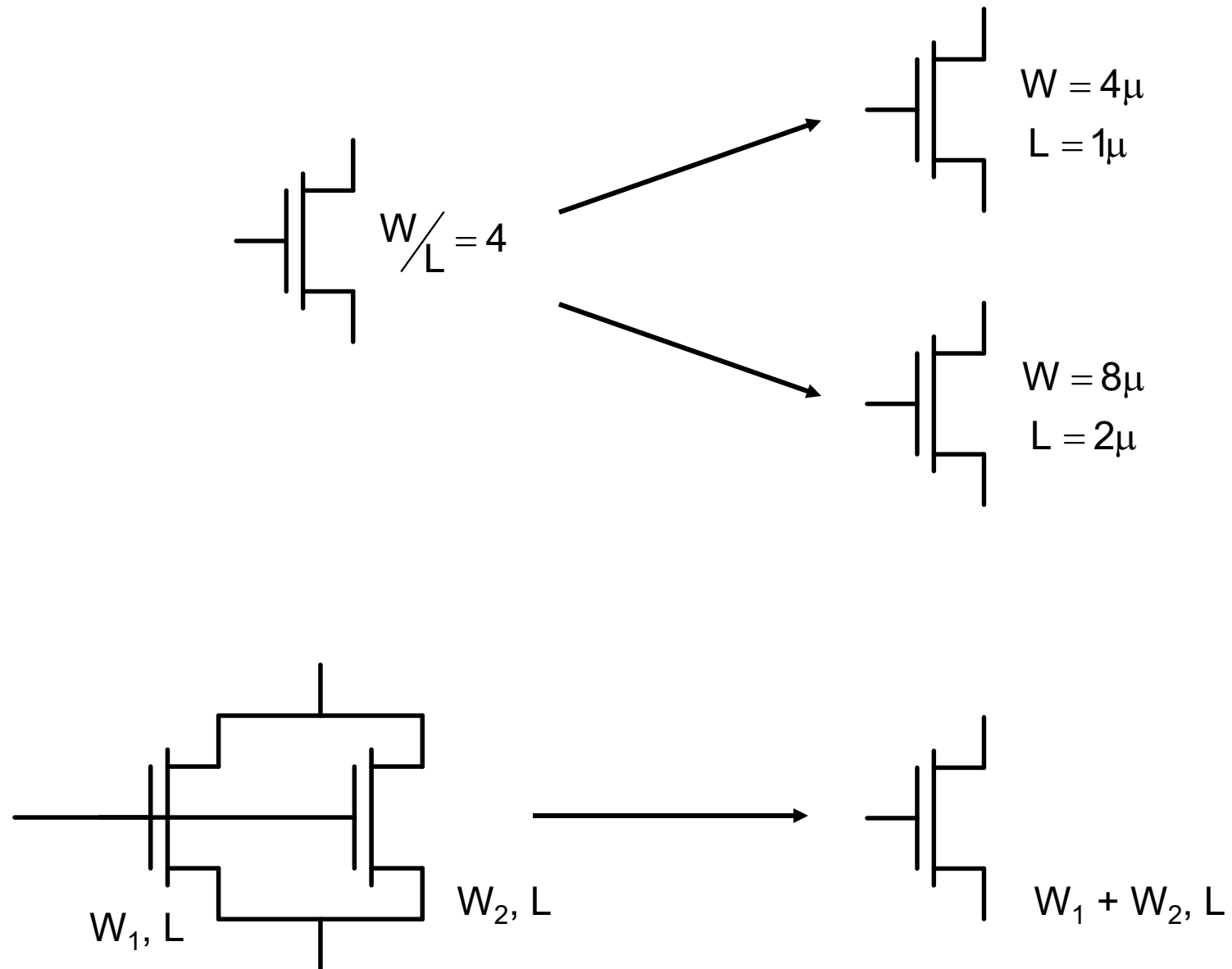
Physical : Describes the constituent blocks to both the transistor and polygon level and their physical placement and interconnection

Multiple representations often exist at any level or sublevel

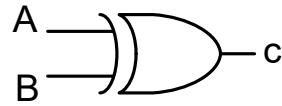
Example: Two distinct representations at the physical level (polygon sublevel)



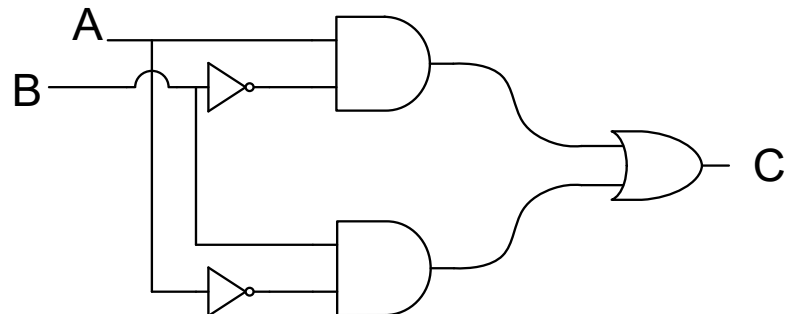
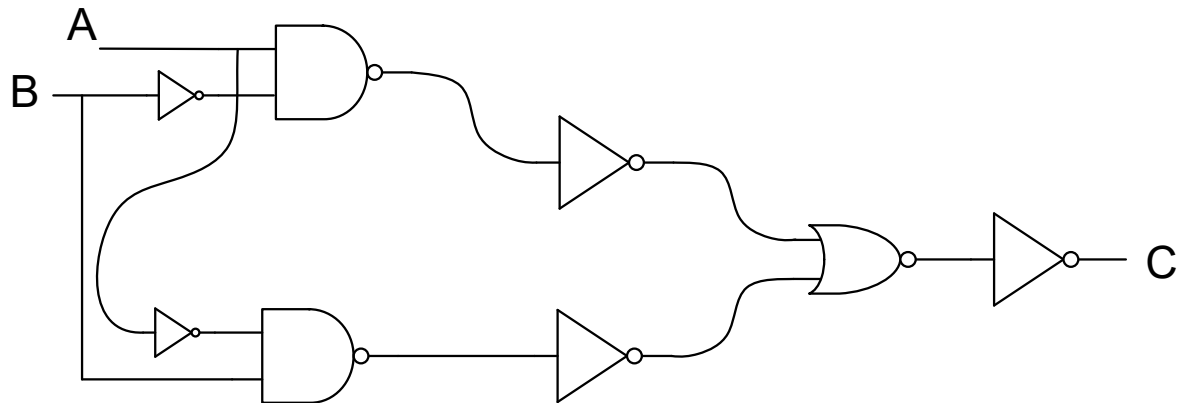
Example: Two distinct representations at physical level (schematic sublevel)



Example: Three distinct representations at the structural/behavioral level (gate sublevel)



$$C = A \oplus B$$



In each domain, multiple levels of abstraction are generally used.

Consider Physical Domain

- Consider lowest level to highest
 - 0 - placement of diffusions, thin oxide regions, field oxide, ect. on a substrate.
 - 1 - polygons identify all mask information
(not unique)
 - 2 - transistors
(not unique)
 - 3 - gate level
(not unique)
 - 4 - cell level
Adders, Flip Flop, MUTs,...

Information Type

PG data

G.D.F

Netlist

HDL Description

Structural Domain:

- DSP
- Blocks (Adders, Memory, Registers, etc.
- Gates
- Transistor

Information Type

HDL

Netlists

Behavior Domain (top down):

- Application
- Programs
- Subroutines
- Boolean Expressions

Information Type

High-Level Language
HDL

Representation of Digital Systems

Standard Approach to Digital Circuit Design

8 – level representation

1. Behavioral Description
 - Technology independent
2. RTL Description (Register Transfer Level)
(must verify (1) \Leftrightarrow (2))
3. RTL Compiler
 - Registers and Combinational Logic Functions
4. Logic Optimizer
5. Logic Synthesis
 - Generally use a standard cell library for synthesis

(sublevels 6-8 not shown on this slide)

Frontend design

Representation of Digital Systems

Standard Approach to Digital Circuit Design

1. Behavioral Description
 - Technology independent
2. RTL Description
 - (must verify (1) \Leftrightarrow (2))
3. RTL Compiler
 - Registers and Combinational Logic Functions
4. Logic Optimizer

5. Logic Synthesis

Generally use a standard cell library for synthesis



Backend design

6. Place and Route

(physically locates all gates and registers and interconnects them)

7. Layout Extraction

- DRC
- Back Annotation

8. Post Layout simulation

May necessitate a return to a higher level in the design flow

Logic synthesis, though extensively used, often is not as efficient nor as optimal for implementing some important blocks or some important functions

These applications generally involve transistor level logic circuit design that may combine one or more different logic design styles



Stay Safe and Stay Healthy !

End of Lecture 36